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FORM PTO-1449		SERIAL NO.	CASE NO.
		08/853,323	7103/30
LIST OF PATENTS AND PUBLICATIONS FOR TRADEMAKES		FILING DATE	GROUP ART UNIT
APPLICANT'S INFORMATION DISCLOSURE STATEMENT		May 8, 1997	3203
(use several sheets if necessary)		APPLICANT(S): Homayoun Talieh et al.	

REFERENCE DESIGNATION		U.S. PATENT DOCUMENTS		
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS/ SUBCLASS
GN	A1 619,399	02/1899	Fischer	—
	A2 3,447,306	06/1969	Jakimcius	—
	A3 3,654,739	04/1972	Stoy et al.	—
	A4 3,753,269	08/1973	Budman	—
	A5 3,906,678	09/1975	Roth	—
	A6 4,016,857	04/1977	Hall	—
	A7 4,347,689	09/1982	Hammond	—
	A8 4,416,090	11/1983	Jonasson	—
	A9 4,593,495	06/1986	Kawakami et al.	—
	A10 4,628,640	12/1986	Johannsen	—
	A11 4,642,943	02/1987	Taylor, Jr.	—
	A12 4,704,823	11/1987	Steinback	—
	A13 4,811,522	03/1989	Gill, Jr.	—
	A14 4,934,102	06/1990	Leach et al.	—
	A15 4,941,293	07/1990	Ekhoff	—
	A16 5,081,795	01/1992	Tanaka et al.	—
	A17 5,205,082	04/1993	Shendon et al.	—
	A18 5,212,910	05/1993	Breivogel	—
	A19 5,230,184	07/1993	Bukhman	—
	A20 5,232,875	08/1993	Tuttle et al.	—
	A21 5,246,525	09/1993	Sato	—
	A22 5,274,964	01/1994	Simpson et al.	—
	A23 5,276,999	01/1994	Bando	—
	A24 5,287,663	02/1994	Pierce et al.	—
	A25 5,297,361	03/1994	Baldy et al.	—
	A26 5,329,732	07/1994	Karlsrud et al.	—
	A27 5,329,734	07/1994	Yu	—
	A28 5,335,453	08/1994	Baldy et al.	—
	A29 5,399,125	03/1995	Dozier	—
	A30 5,456,627	10/1995	Jackson et al.	—

## FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS/ SUBCLASS	TRANSLATION YES NO
GN	A31 EP 517 594	12/92	EPO	—	
GN	A32 EP 517 595	12/92	EPO	—	

EXAMINER G. NGUYEN	DATE CONSIDERED 2/9/98
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

FORM PTO-1449		O/A LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT (use several sheets if necessary)	SERIAL NO. 08/853,323	CASE NO. 7103/30
		2 1038 INT'L TRADE MARKS	FILING DATE May 8, 1997	GROUP ART UNIT 3203
APPLICANT(S): Homayoun Talieh et al.				

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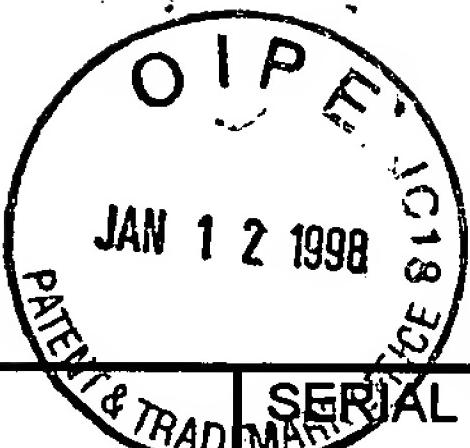
## FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS/ SUBCLASS	TRANSLATION YES	NO
GN	A33 2269552	11/1990	Japan	—		
GN	A34 2269553	11/1990	Japan	—		
GN	A35 62162466	7/87	Japan	—		
GN	A36 63267155	11/88	Japan	—		
GN	A37 7111256	04/1995	Japan	—		
GN	A38 JP 59-232768	12/1984	Japan	—		
GN	A39 JP 63200965	08/1988	Japan	—		
GN	A40 JP 63251166	10/1988	Japan	—		
GN	A41 JP 4-250967	09/1992	Japan	—		
GN	A42 DE 3411 120 A1	03/1983	Germany	—		
GN	A43 PCT WO 94/17957	08/1994	PCT	—		
GN	A44 2007784	6/1994	Russia	—		

EXAMINER INITIAL	OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)	
GN	A45	"A New Pad and Equipment Development for ILD Planarization" by Toshiyasu Beppu, Motoyuki Obara and Yausuo Minamikawa, Semiconductor World, January, 1994, MY 3/17/94
GN	A46	"Application of Chemical Mechanical Polishing to the Fabrication of VLSI Circuit Interconnections", William J. Patrick, William L. Guthrie, Charles L. Stadley and Paul M. Schiable, J. Electrochem. Soc., Vol. 138, No. 6, June 1991, pp. 1778-1784
GN	A47	"Theory & Practice of Lubrication for Engineers", Dudley Fuller, Wiley-Interscience, 1st ed., pp. 22-25 and 86
GN	A48	Practical Ideas, June 1994, page 67

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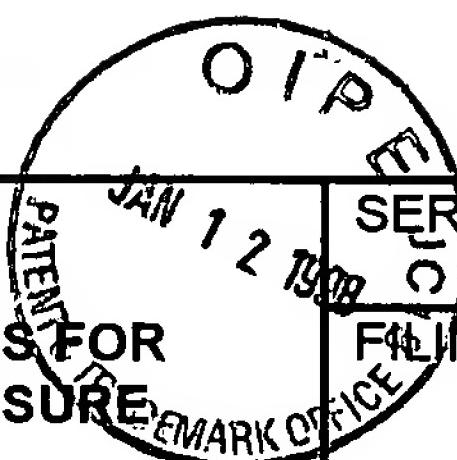
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**LIST OF PATENTS AND PUBLICATIONS FOR  
APPLICANT'S INFORMATION DISCLOSURE  
STATEMENT**

(use several sheets if necessary)

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